
R&D for Advanced Photo-Cathode

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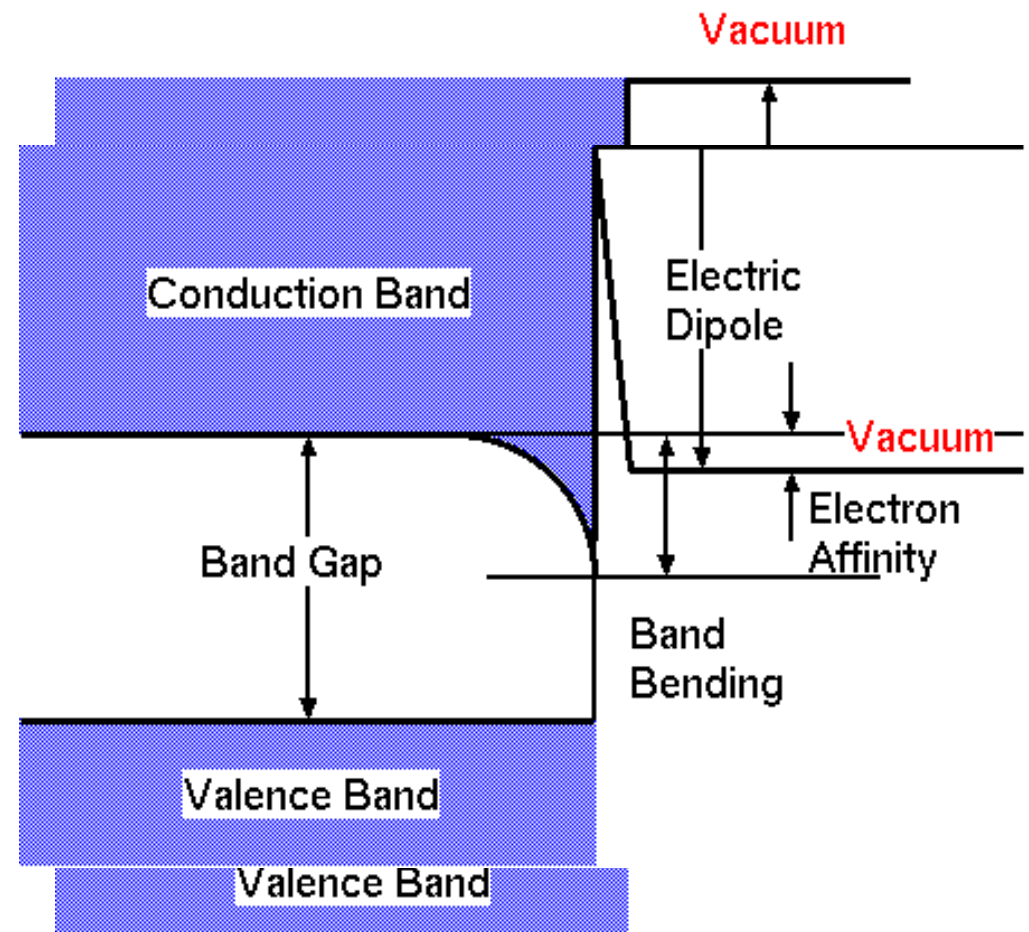
- ▶ Advanced Photo-cathode
- ▶ Band Structure Optimization
- ▶ Super High Vacuum
- ▶ R&D plan
- ▶ Summary

Goal of Cathode R&D

- ▶ High performance: Super-low emittance, high polarization
- ▶ High Power : High Quantum efficiency, Optimized for high power laser
- ▶ Long Operational lifetime
 - Robust cathode
 - Less damage by better vacuum
- ▶ Introduce to the Q-beam system, ERL, ILC, CLIC, SRIPES, SPLEEM, etc.

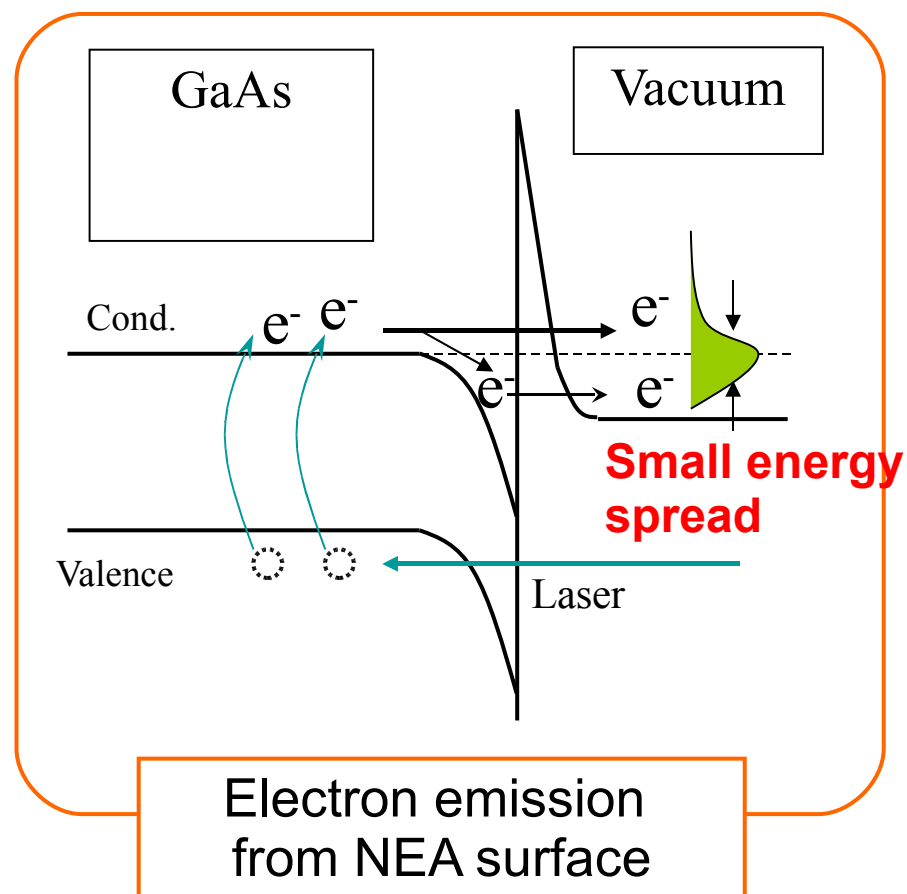
GaAs cathode and EA

- ▶ GaAs : NEA surface is artificially made.
 - PEA (Positive Electron Affinity): electron in conduction band is confined.
 - NEA (Negative Electron Affinity): electrons in conduction band is extracted to vacuum.



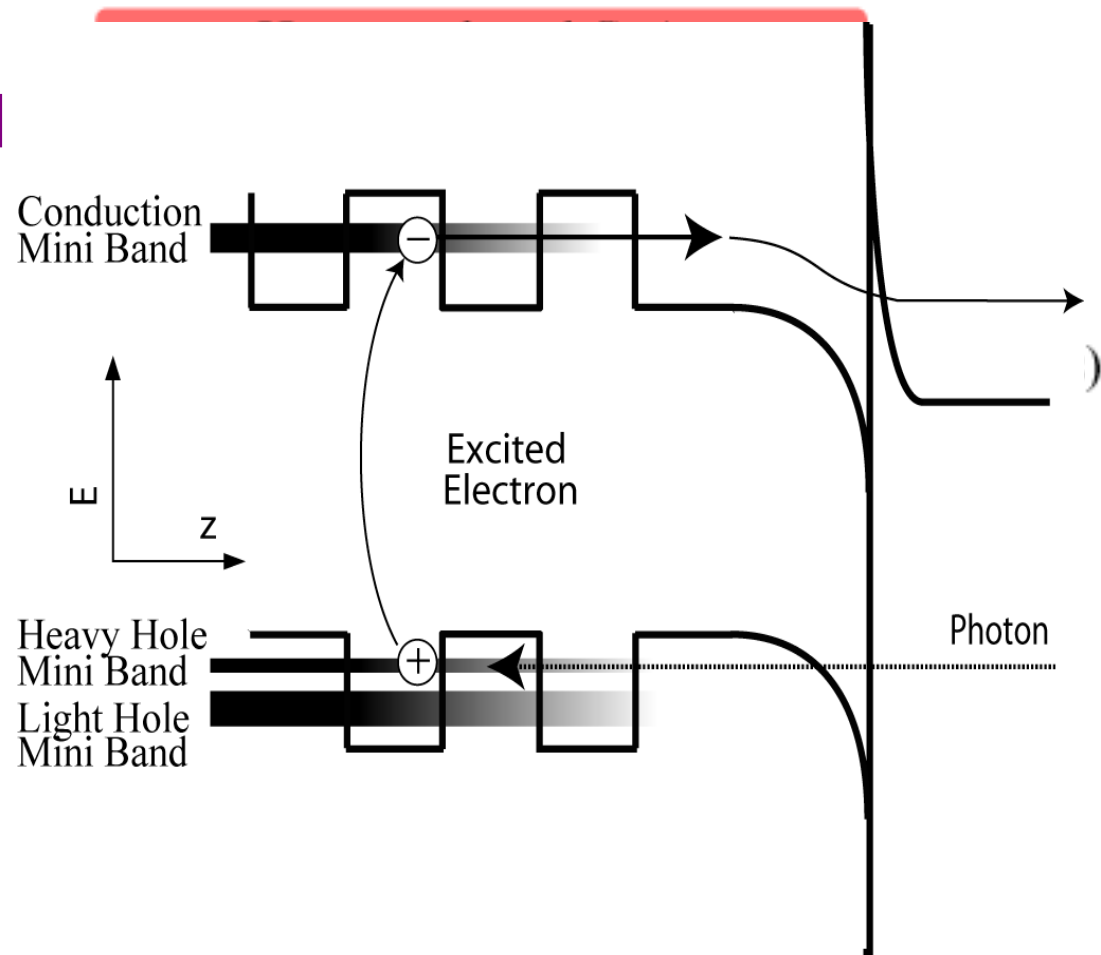
Electron emission from NEA

- ▶ Electron excited to conduction band is easily emitted to vacuum : High Quantum efficiency (1-20%)
- ▶ Excitation by optimized laser and thermalization results that the electron beam has small energy spread: super-low emittance beam
- ▶ Helicity selection by circularly polarized laser : polarized electron.



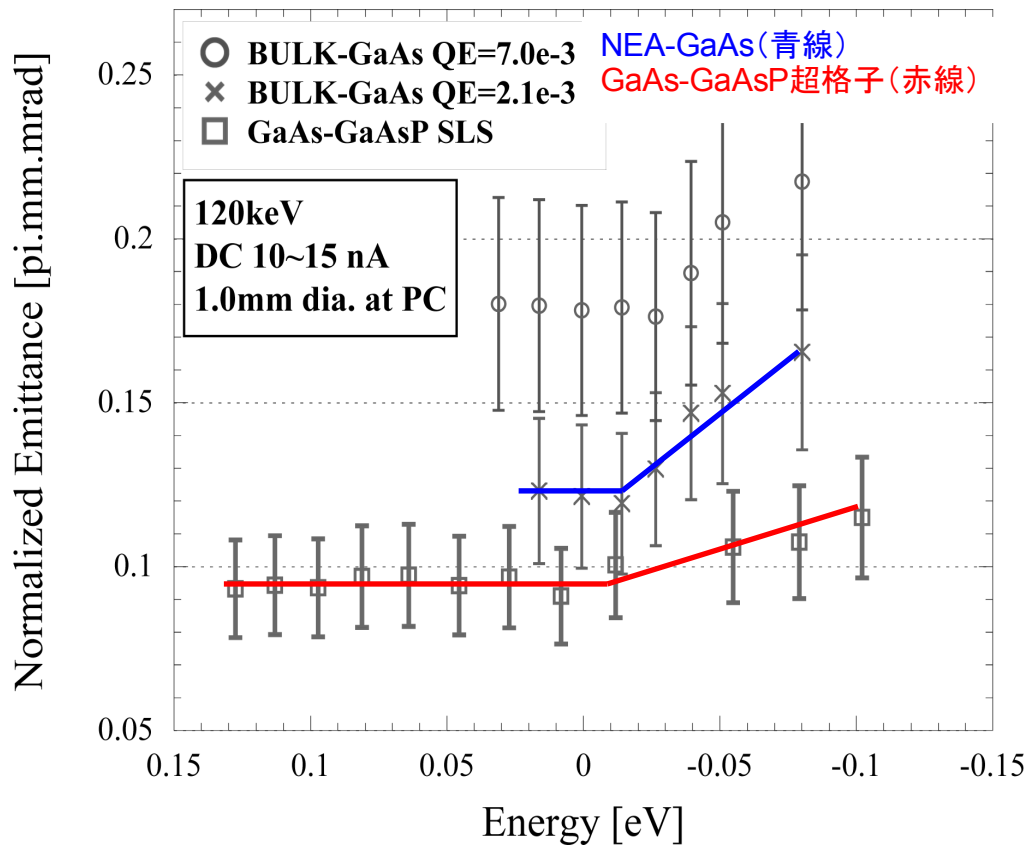
Super-lattice Cathode

- ▶ GaAs-GaAsP super-lattice: Mini-band is formed in conduction and valence bands, respectively.
- ▶ Selection on the transition is enhanced both for energy and helicity.
 - High polarization (90%)
 - Super-low emittance (0.1mm.mrd)



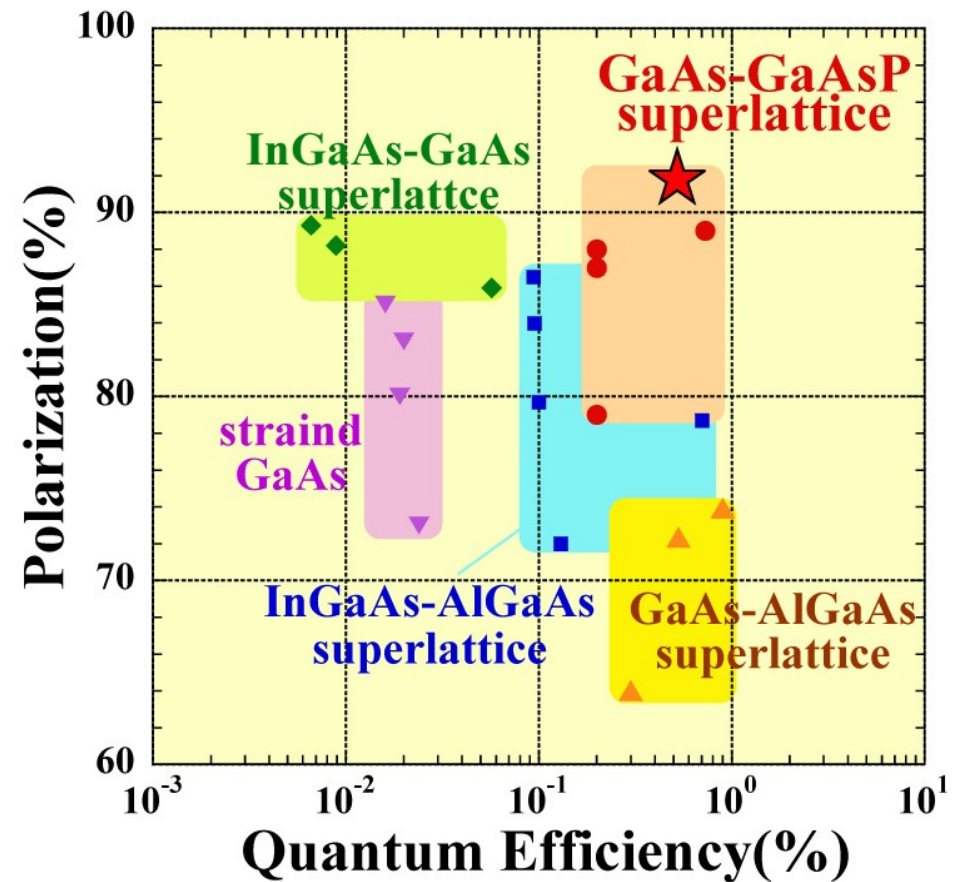
Super-lattice Cathode

Super-low emittance



Nagoya-KEK

High Polarization



Nagoya

Issues for GaAs cathode

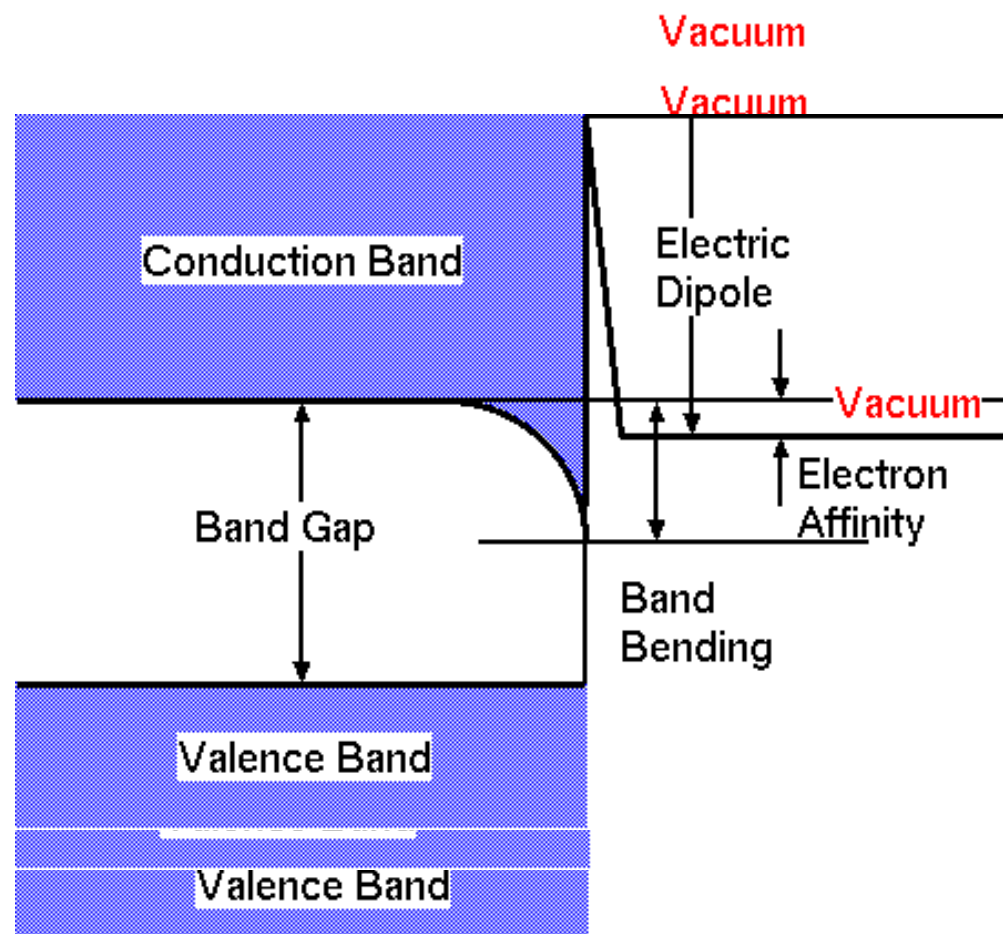
- ▶ GaAs-GaAsP super-lattice cathode is developed for high polarization (ILC), but it is also useful for super-low emittance cathode (ERL).
- ▶ Performance is excellent, but the operational lifetime is limited.
 - Robust cathode
 - Super high vacuum

Issues for GaAs cathode

- ▶ Band gap energy of GaAs cathode corresponds to 800nm.
- ▶ Ti:S laser is widely used, but high average power operation is critical due to thermal effects and less efficiency for pumping.
- ▶ If the band gap is optimized to 500nm, SH of a stable full solid-state laser (Yb:YAG, Yb fbr, etc) can be used for the drive laser without emittance increment.
- ▶ E_g optimization to 500nm is desirable for high power and super-low emittance beam.

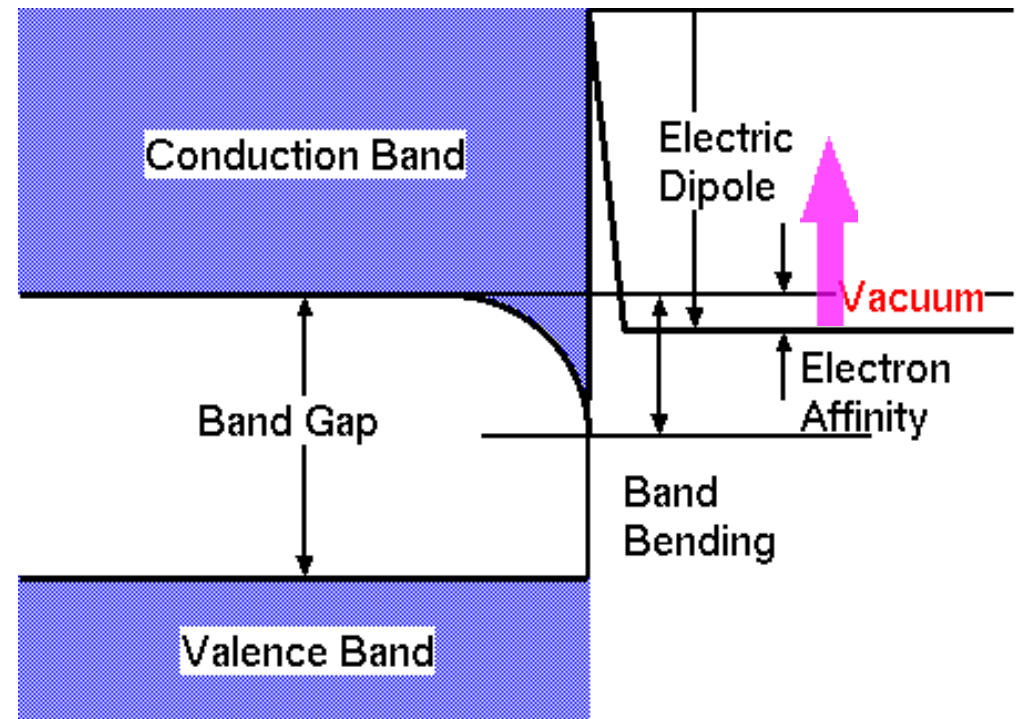
Band Structure Optimization

- ▶ NEA surface is made by two treatment.
 - Band bending by P-doping: $E_{BB} \propto E_g$
 - Electric dipole by cesiation: E_{Cs}
 - $E_a = E_{a0} - E_{BB} - E_{Cs}$
- ▶ Smaller E_a is achieved with smaller E_{a0} and larger E_g .



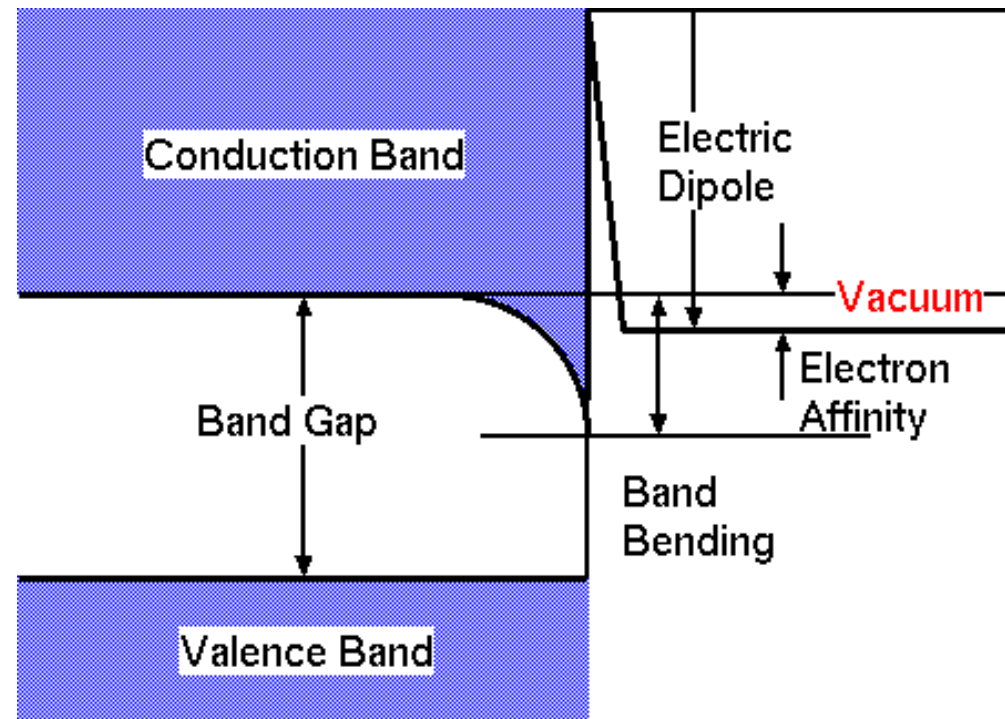
Damage on Cathode

- ▶ Damage on Cs layer (NEA surface) increases E_a , which degrades the electron emission.
- ▶ The limited operation life time is caused by this damage.
- ▶ If the initial NEA is large, the operational life time could be longer.
- ▶ Super high vacuum is also helpful.



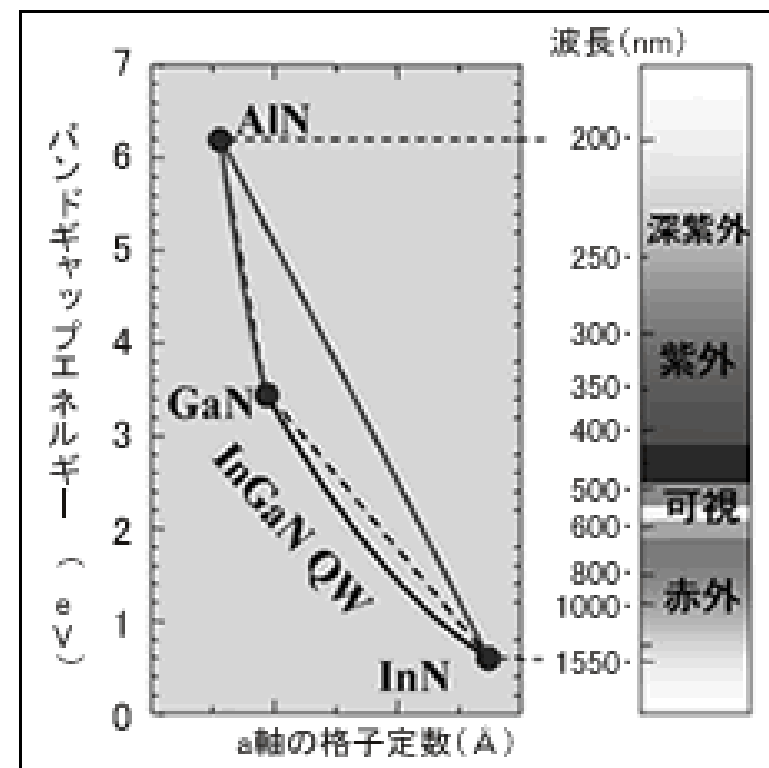
Band Structure Optimization, Again

- ▶ $E_a = E_{a0} - E_{BB} - E_{cs}$
- ▶ Smaller E_a is achieved with smaller E_{a0} and larger E_g .
- ▶ Materials with small E_{a0} and larger E_g is candidates of robust cathode.



AlGaAs/InGaN Cathode

- ▶ Band gap energy, E_g and electron affinity, E_{a0} :
 - GaAs $E_g=1.42\text{eV}$, $E_{a0}=4.1\text{eV}$
 - AlAs $E_g=2.17\text{eV}$, $E_{a0}=3.5\text{eV}$
 - GaN $E_g = 3.3\text{eV}$, $E_{a0}=4.1\text{eV}$
 - InN $E_g=0.6-2.0\text{eV}$, $E_{a0}=??$
- ▶ AlAs, GaN : Large E_g
 - Longer life time
 - Smaller wave length
- ▶ $\text{Al}_x\text{Ga}_{1-x}\text{As}$, $\text{In}_x\text{Ga}_{1-x}\text{N}$:
Optimization on E_g and E_{a0} by Mixed Crystal.



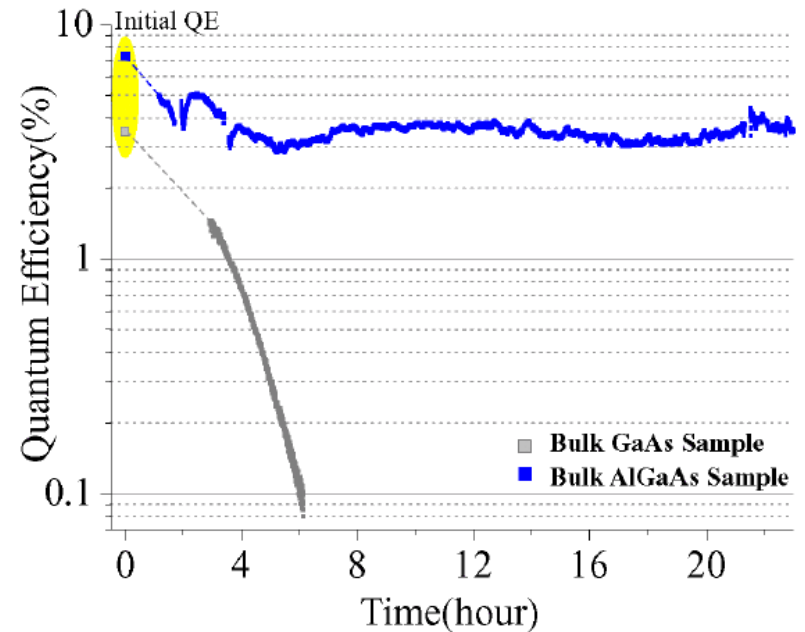
AlGaAs/InGaN Cathode

▶ $\text{Al}_x\text{Ga}_{1-x}\text{As}$:

- Longer lifetime than that of GaAs is already demonstrated.
- Larger E_g makes less E_a .

▶ $\text{In}_x\text{Ga}_{1-x}\text{N}$:

- Longer lifetime is expected because of large E_g .
- E_g optimization to 500nm laser is also possible.



T. Nishitani et al., Proc. of the 28th International FEL Conf. (FEL2006), pp319-322, 2006

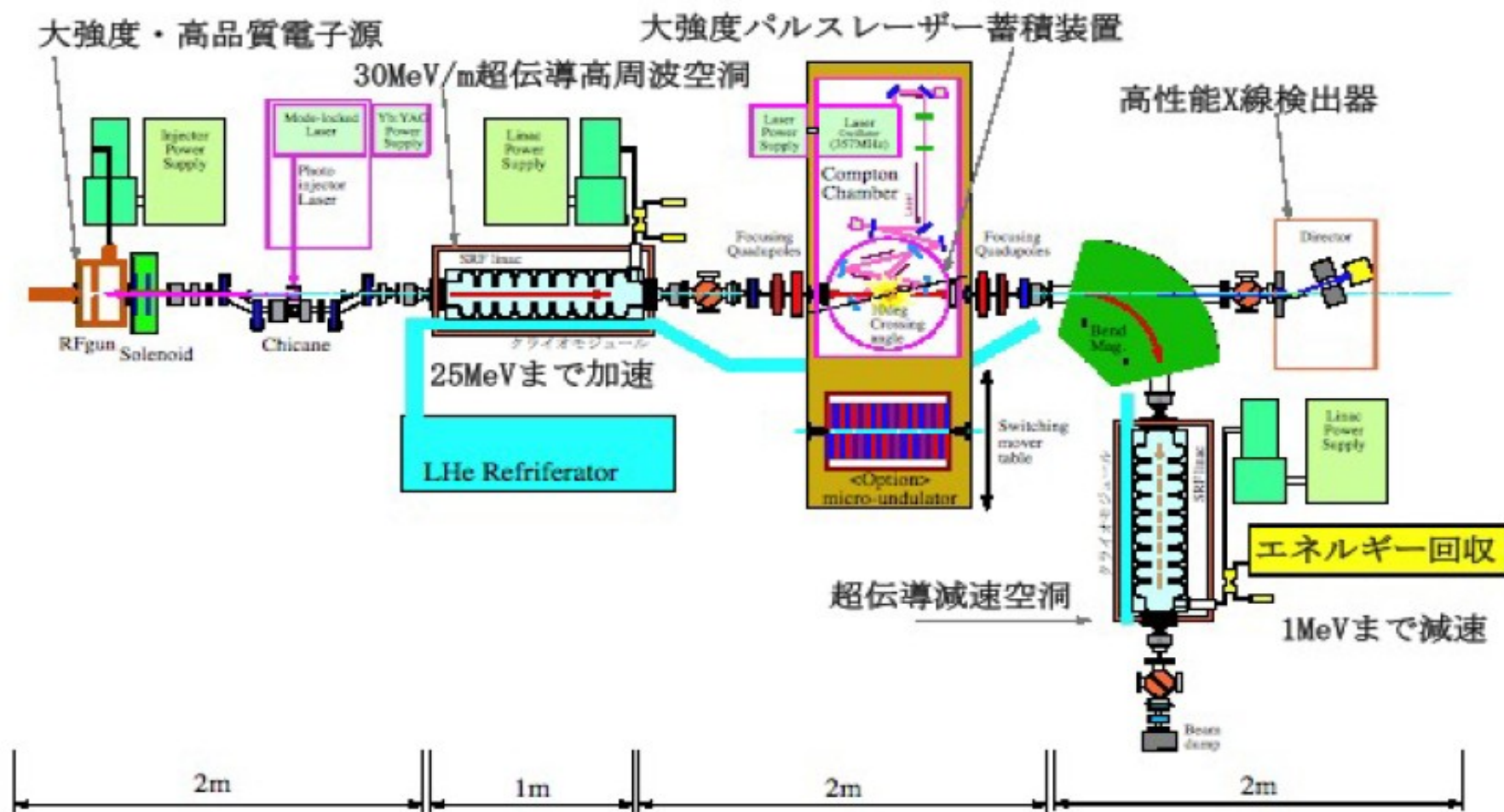
Super High Vacuum

- ▶ Limited operational lifetime of GaAs cathode
 - Chemical dilution by H₂O, Hydrocarbon, etc.
 - Ion back-bombardment.
- ▶ These effects should be compensated by better vacuum
 - Current : 1E-8~1E-9Pa
 - Goal : 1E-10~1E-11Pa

Super High Vacuum (2)

- ▶ EP SUS chamber + Ion pump + NEG pump: $1\text{E}-9\text{Pa}$
 - Pumping speed is decreased in super-high vacuum.
 - Pump is a source of out gas.
- ▶ CP Ti chamber + Cryo-pump + NEG : less than $1\text{E}-10\text{Pa}$?
 - Cryo-pump is better than Ion pump for Super high vacuum?
 - CP Ti has less out gas rate than that of EP SUS.

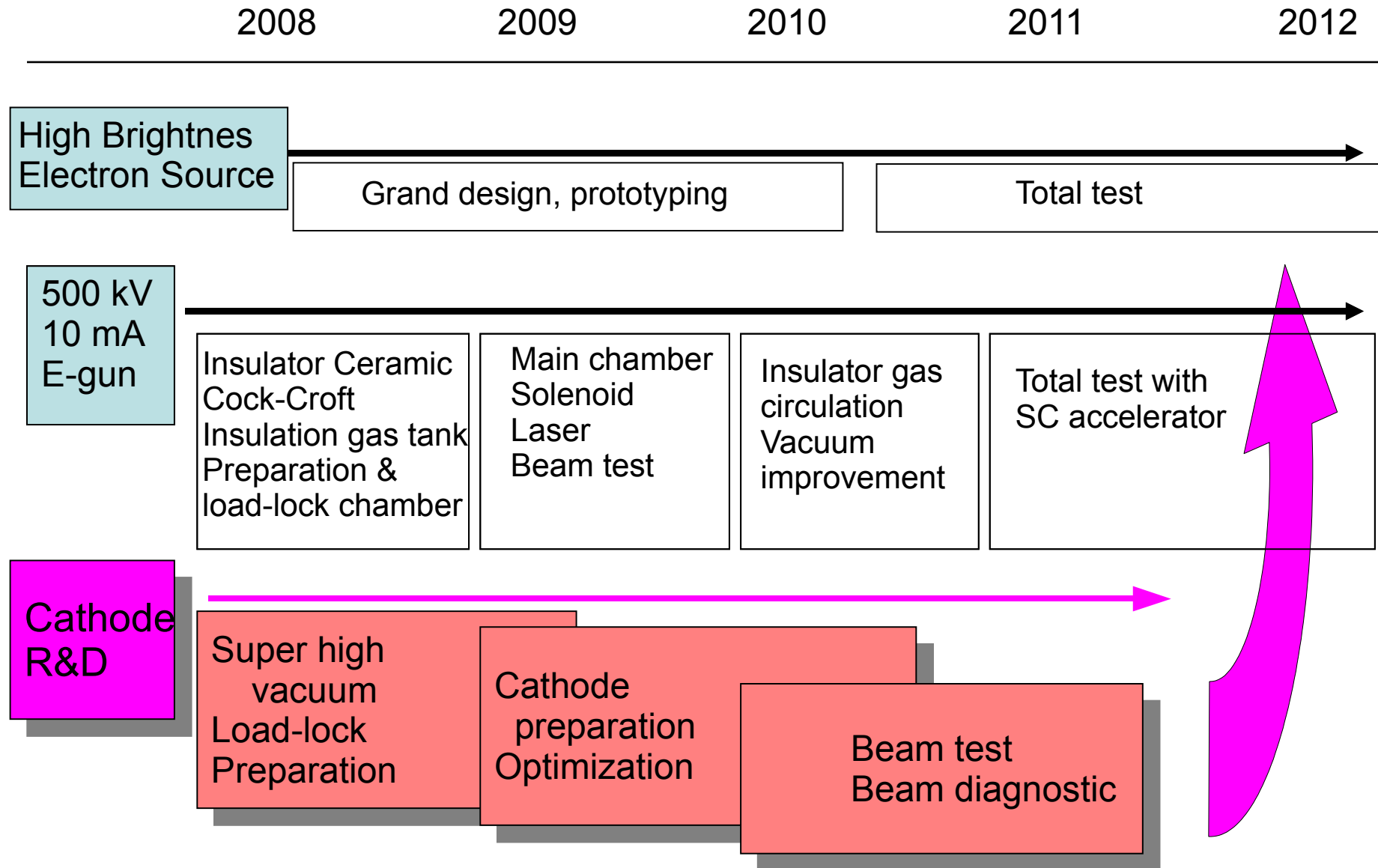
Q-beam System



R&D Plan

- ▶ 2008-2009 : Cathode Test Chamber
 - Super high vacuum chamber design and manufacturing: CP Ti chamber + Cryo-pump + NEG pump
 - Load-lock chamber, Activation chamber design and manufacturing
- ▶ 2009-2010 : AlGaAs, InGaN cathode preparation, optimization
- ▶ 2011 : Further optimization, beam test
- ▶ 2012 : Implementation to the electron gun

Electron source R&D plan in Quantum Beam Project



Summary

- ▶ Long life time cathode and high power operation are aimed for future projects;
 - Band structure optimization on $\text{Al}_x\text{Ga}_{1-x}\text{As}$, $\text{In}_x\text{Ga}_{1-x}\text{N}$
 - Longer lifetime by smaller E_a
 - 500nm E_g driven by SH of solid state laser
 - Super high vacuum for less damage on cathode
 - CP Ti chamber
 - Cryo-pump + NEG pump
- ▶ Robust and high power cathode will be introduced to the final system of Q-beam project, ERL, ILC, CLIC, SRIPES, SPLEEM, etc.

Back Up Slides

Grand Plan

項目	1年度目	2年度目	3年度目	4年度目	5年度目
超伝導空洞装置開発 (年額 3.1 億円、 その他 0.5 億円含む)	→			}	}
空洞製作技術高度化 超伝導空洞製作 高周波源小型化 ビーム制御機器開発					
電子源開発 (年額 0.53 億円)	→				
高効率・長寿命フォトカソード開発 500 kV 直流電子源開発 ビーム生成実験				}	}
レーザー蓄積・ X線検出装置開発 (年額 0.21 億円)	→				
レーザー蓄積装置設計 レーザー蓄積装置製作 X線検出器試験					
				}	
				→	
				システム組立・調整 総合試験・性能確認	